

**In the Specification**

At page 1 before the "Technical Field" section, please insert the following:

**--RELATED PATENT DATA**

This patent resulted from a divisional application of U.S. Patent Application Serial No. 10/293,072, filed November 12, 2002, entitled "Atomic Layer Deposition Methods", naming Trung Tri Doan, Guy T. Blalock, and Gurtej S. Sandhu as inventors, the disclosure of which is incorporated by reference.--

**In the Claims**

Cancel claims 1-63.

**REMARKS**

This application is a divisional application of U.S. Patent Application Serial No.10/293,072. Original claims 1-63 have been cancelled without prejudice. Claims 64-99 remain in the application for consideration.

Respectfully submitted,

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By:   
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